

PATENT

Case Docket No.:

99 P 7722 US (8055-98)

Date: September 18, 2002

ASSISTANT COMMISSIONER FOR PATENTS -Washington, D.C. 20231 **Box PATENT APPLICATION**

Transmitted herewith is an amendment in the identified application noted below.

No additional fee is required.

In re application of:

Jammy

et al.

Serial No.:

09/363,523

Filed:

July 29, 1999

For:

METHOD FOR FORMING CRYSTALLINE SILICON NITRIDE

The filing fee has been calculated as shown below:

	(Col. 1)	(Col. 2)	(Col. 3)	OTHER SMALL &	ENTITY		
CLAIMS	. CLAIMS REMAINING AFTER AMENDMENT	HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDIT. FEE	ТЕСН	٠
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Respectfully submitted,

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Attorney for Applicant

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September 18, 2002

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Attorney Docket: 8055-98 (99-P-7722-US)

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Jammy et al.

Examiner: Estrada, Michelle

Serial No: 09/363,523

Group Art Unit: 2823

Filed: July 29, 1999

Docket: 8055-98 (99-P-7722-US)

METHOD FOR FORMING CRYSTALLINE SILICON NITRIDE For:

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

or of the U.S. Patent and Trademark Office

ngton, D.C. 20231

RESPONSE

This is a response to the office action mailed on June 18, 2002. Please consider Be following remarks.

CERTIFICATE OF MAILING 37 C.F.R. § 1.8(a)

I hereby certify that this correspondence (and any document referred to as being attached or enclosed) is being deposited with the United States Postal Service as first class mail, postage paid in an envelope addressed to: Director of the U.S. Patent and Trademark Office, Washington, D.C. 20231 on September 18, 2002.

Frank DeRosa